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	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
APPLICATION NO.	FILING DATE		0020-4666P	1396
09/492,803	01/28/2000	Fumihiro Konushi	0020 -4 666F	1370
2292 7590 01/15/2002 BIRCH STEWART KOLASCH & BIRCH PO BOX 747			EXAMINER LEUNG, QUYEN PHAN	
FALLS CHUR	CH, VA 22040-0747			AMINER
			ART UNIT	PAPER NUMBER
			2828	

DATE MAILED: 01/15/2002

Please find below and/or attached an Office communication concerning this application or proceeding.

			ps.			
		Application No.	Applicant(s)			
	•	09/492,803	KONUSHI ET AL.			
	Office Action Summary	Examiner	Art Unit			
		Quyen P. Leung	2828			
	Th MAILING DATE of this communication app	ars on the cover she	t with th correspondence address			
Period fo	or Reply					
THE I - Exter after - If the - If silu - Failu	ORTENED STATUTORY PERIOD FOR REPL' MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a repl period for reply is specified above, the maximum statutory period or tre to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, m	of thirty (30) days will be considered timely. MONTHS from the mailing date of this communication. MANDONED (35 U.S.C. § 133).			
1) 🖂	Responsive to communication(s) filed on 01	November 2001 .				
2a)□		his action is non-final.				
3)	This dotter to the merits is					
Disposit	tion of Claims					
4)🖂	Claim(s) 1-22 is/are pending in the application	n.				
	4a) Of the above claim(s) is/are withdra	awn from consideration	٦.			
5)□	Claim(s) is/are allowed.					
6)⊠	Claim(s) <u>1-22</u> is/are rejected.					
7)□	· ·					
8) 🗌	Claim(s) are subject to restriction and/	or election requiremen	nt.			
Applica	tion Papers					
9) 🗆	The specification is objected to by the Examin					
10)		epted or b)⊡ objected t				
	Applicant may not request that any objection to t	the drawing(s) be held in	abeyance. See 37 CFR 1.85(a).			
11)	The proposed drawing correction filed on					
	If approved, corrected drawings are required in r					
] The oath or declaration is objected to by the E	xaminer.				
Priority	under 35 U.S.C. §§ 119 and 120		0.0 \$ 440(a) (d) az (9			
	Acknowledgment is made of a claim for forei	gn prionty under 35 U	.5.C. 8 119(a)-(u) or (i).			
a	a) ☐ All b) ☐ Some * c) ☐ None of:					
	1. Certified copies of the priority docume	nts have been receive	G.			
	2. Certified copies of the priority docume	nts have been receive	d in Application No			
	3. Copies of the certified copies of the prapplication from the International Essee the attached detailed Office action for a lie	Bureau (PC Rule 17.4	2(a)).			
14)	Acknowledgment is made of a claim for dome	stic priority under 35 L	J.S.C. § 119(e) (to a provisional application).			
	a) ☐ The translation of the foreign language p ☐ Acknowledgment is made of a claim for dome	provisional application	has been received.			
Attachme		,				
1) No	otice of References Cited (PTO-892) Otice of Draftsperson's Patent Drawing Review (PTO-948) Formation Disclosure Statement(s) (PTO-1449) Paper No(s	5) 🔲 No	terview Summary (PTO-413) Paper No(s) otice of Informal Patent Application (PTO-152) her:			

U.S. Patent and Trademark Office PTO-326 (Rev. 04-01)

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DETAILED ACTION

Response to Amendment

1. In response to applicant's amendment filed 11/1/2001, claim 1 has been amended and claims 9-22 added.

Response to Arguments

2. Applicant's arguments with respect to claims 1-8 have been considered but are moot in view of the new ground(s) of rejection.

Claim Rejections - 35 USC § 112

- 3. The following is a quotation of the second paragraph of 35 U.S.C. 112:
 The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 4. Claims 17, 19 and 21 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 17 recites the limitation "said stripe-shaped ridge" in line 2. There is lack of antecedent basis for this limitation.

Claim 19 recites the limitation "a width of 4 –5 um" in line 2. It is unclear what the width should be since its parent claim, claim 17, recites a width of 2 - 3 um.

Claim 21 recites the limitation "a width of 2-2.5 um" in line 2. It is unclear what the width should be since its parent claim, claim 19, recites a width of 4-5 um.

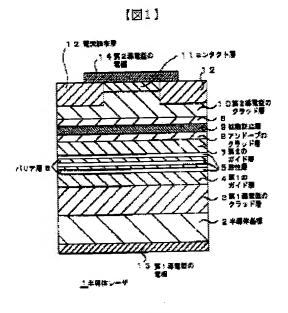
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Claim Rejections - 35 USC § 102

5. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 6. Claims 1, 6, 9, 10, 12, 18 are rejected under 35 U.S.C. 102(b) as being anticipated by Sony (JP 10-209573 A). (See also the English language equivalent US 6,233,266 B1) Sony discloses the claimed invention. Sony teaches a semiconductor



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laser

device having a quantum well active layer 5 disposed between a pair of cladding layers 3, 10, and an optical guide layer 4, 7 disposed between at least one of the cladding

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layers **3,10** and the quantum well active layer **5**, wherein a spacer layer **9** is provided between the optical guide layer **4,7** and said at least one of the cladding layers **3,10**.

Claim Rejections - 35 USC § 103

- 7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- Claims 2-3, 5, 7-8, 11, 13-17, 19-21 are rejected under 35 U.S.C. 103(a) as 8. being unpatentable over Sony as applied above. Sony has been discussed above except for (1) the optical guide layer thickness of 30 nm or 35 nm, or (2) each of the well layers having a thickness of 8 or 7 nm and each of the optical barrier layers of 5, 8 or 20 nm, or (3) a ridge width of 2-3 microns, or (4) the undoped spacer layer 9 having a thickness of 5 nm or more but below 10 nm or (5) the ratio of the feed rate between 50 to 200 inclusively or (6) the p-type cladding layer 10 having a carrier concentration range between 8x10¹⁷ cm⁻³ to 5x10¹⁸ cm⁻³. It would have been obvious to one having ordinary skill in the art at the time the invention was made to have (1) the optical guide layer thickness of 30 nm or 35 nm, or (2) each of the well layers having a thickness of 8 or 7 nm and each of the optical barrier layers of 5, 8 or 20 nm or (3) a ridge width of 2-5 microns, or (4) the undoped spacer layer 9 having a thickness of 5 nm or more but below 10 nm, or (5) the ratio of the feed rate between 50 to 200 inclusively, or (6) the ptype cladding layer 10 having a carrier concentration range between 8x10¹⁷ cm⁻³ to 5x10¹⁸ cm ⁻³ since it has been held that discovering an optimum value of a result

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effective variable involves only routine skill in the art. *In re Boesch*, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

9. Claim 4 and 22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sony in view of Ohba et al (5,034,957). Sony has been discussed above except for the spacer having a carrier concentration being more than 5×10^{16} cm⁻³ and less than 5×10^{17} cm⁻³. In col. 7 lines 22-27, Ohba et al teaches a carrier concention of 2.5×10^{17} cm⁻³ in the spacer for the advantageous benefit of suppressing the diffusion of Zn into the active layer. It would have been obvious to one of ordinary skill in the art to modify Sony by employing the spacer having a carrier concentration being more than 5×10^{16} cm⁻³ and less than 5×10^{17} cm⁻³, as taught by Ohba et al , so as to gain the advantageous benefit of suppressing the diffusion of Zn into the active layer.

Conclusion

10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Quyen P. Leung whose telephone number is (703) 308-0545. The examiner can normally be reached on 8:30-5:00, M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Paul Ip can be reached on (703) 308-3098. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 308-7724 for regular communications and (703) 308-7724 for After Final communications.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Quyen . Leung Primary Examiner Art Unit 2828

QPL January 14, 2002